

In the Specification:

On page 1, after the title insert:

CROSS-REFERENCE TO RELATED APPLICATIONS

This a section 371 application of International Application No.: PCT/DE2004/002465 filed November 4, 2004, and published, in German, as International Publication No. WO 2005/045091 A2 on May 19, 2005, which claims priority from German application 103 52 144.5 filed on November 4, 2003, which applications are hereby incorporated by reference herein in their entirety.

BACKGROUND OF THE INVENTION

On page 2, in line 3 insert:

BRIEF SUMMARY OF THE INVENTION

On page 4, in line 27 insert:

BRIEF SUMMARY OF THE DRAWING FIGURES

On page 4, in line 36 insert:

DETAILED DESCRIPTION

On page 5, rewrite the first paragraph to read as follows:

The substrate 5 from above is arranged above the substrate plane 6, the target surface 7 being opposite to the top side of the substrate 5. In the right-hand section of the vacuum coating system 1, a coating system in sputter-up mode 8 is arranged between two pump sections 2. Here, coating is carried out from ~~above~~below onto the substrate 5, in that a magnetron 4 is arranged below the substrate plane 6, the target surface 7 being opposite to the underside of the substrate 5.



On page 6, kindly rewrite the paragraph to read as follows:

Substrate width on the substrate 5 below the transport plane 11. For a ~~multivalent~~ variant use of the pump sections 2, the vacuum pump 19 is arranged in the conventional arrangement on the pump section 2 for upward suction or alternatively below the transport plane 11 for lateral suction.

At the end of the application, kindly add the Abstract of the Disclosure as presented on the following page: